| L | Hits | Search Text | DB | Time stamp |
|--------|------|------------------------------------------------------------------------------------------------------------------------------------------------------|---------------------------------------------|---------------------|
| Number | 220 | 212/6 | | |
| _ | 220 | 313/\$.ccls. and organic and sulfur | USPAT; US-PGPUB; EPO; JPO | 2003/09/29 14:23 |
| _ | 0 | 313/326.ccls. and (carbon and sulfur) | USPAT; US-PGPUB; | 2002/06/14 14:16 |
| _ | 767 | 313/310.ccls. | EPO; JPO USPAT; US-PGPUB; | 2002/06/14 14:16 |
| _ | 127 | 252/519.4.ccls. | EPO; JPO USPAT; US-PGPUB; | 2002/06/14 14:18 |
| _ | 828 | or "electron emitting" or display) and | EPO; JPO USPAT; US-PGPUB; | 2002/06/14 14:20 |
| _ | 844 | film and electrode 313/495.ccls. | EPO; JPO USPAT; US-PGPUB; | 2002/06/14 14:20 |
| _ | 11 | 252/519.4.ccls. and "thin film" | EPO; JPO USPAT; US-PGPUB; | 2002/06/14 14:20 |
| _ | 5 | (313/306.ccls. or 313/308.ccls.) and sulfur | EPO; JPO USPAT; US-PGPUB; | 2002/06/14 14:20 |
| _ | 18 | 313/495.ccls. and (carbon and sulfur) | EPO; JPO USPAT; US-PGPUB; | 2002/06/14 14:20 |
| - | 7 | 252/519.14.ccls. and carbon and sulfur | EPO; JPO USPAT; US-PGPUB; | 2002/06/14 14:20 |
| - | 17 | 252/519.4.ccls. and carbon and sulfur | EPO; JPO USPAT; US-PGPUB; | 2002/06/14 14:20 |
| ī | 148 | sulfur and (conductor or semiconductor) | EPO; JPO USPAT; US-PGPUB; | 2002/06/14 14:20 |
| - | 2156 | deposition) and semiconductor not photographic not ink not batteries not | EPO; JPO USPAT; US-PGPUB; EPO; JPO | 2002/12/01 22:35 |
| - | 4 | battery "6267636" | USPAT; US-PGPUB; EPO; JPO | 2002/12/01 22:31 |
| - | 109 | 313/\$.ccls. and (carbon or organic) same sulfur and (conductor or semiconductor) and substrate | USPAT; US-PGPUB; EPO; JPO | 2002/12/01 22:32 |
| - | 239 | (Carbon same Sulfur) same (film or deposition) and semiconductor not photographic not ink not batteries not | USPAT; US-PGPUB; EPO; JPO | 2002/12/01 22:43 |
| - | 187 | battery (Carbon same Sulfur) same (film or deposition) and semiconductor not | USPAT; US-PGPUB; | 2002/12/01 22:43 |
| _ | 7 | photographic not ink not batteries not battery not tetrafluoride | EPO; JPO | |
| | | (Carbon same Sulfur) same (film or deposition) and semiconductor not photographic not ink not batteries not battery not tetrafluoride and carbon.ti. | USPAT; US-PGPUB; EPO; JPO | 2002/12/01 22:51 |
| - | 33 | (Carbon same Sulfur) same (film or deposition) not photographic not ink not batteries not battery not tetrafluoride | USPAT; US-PGPUB; EPO; JPO | 2002/12/02 02:06 |
| - | 40 | and "carbon film" (Carbon same Sulfur) same (film or deposition or layer) not photographic not ink not batteries not battery not | USPAT; US-PGPUB; EPO; JPO | 2002/12/02 02:09 |
| | | tetrafluoride and "carbon film" | | |

| (film or deposition) not photographic not ink not batteries not battery not tetrafluoride and (carbon near2 film?) | - | 26 | ((Carbon or diamond) same (Sulfur)) same | USPAT; | 2002/12/02 |
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| (film or deposition or layer) not photographic not ink not batteries not battery not tetrafluoride and ((carbon or Diamond) near? film?) 477 (carbon same sulfur) and ("image forming" or "electron emitting" or display) and film and electrode not genes not human not (sulfur same impurities) not hexafluoride not photographic 20 (carbon same sulfur) and ("electron emitting") and film and electrode not genes not human not (sulfur same impurities) not hexafluoride not photographic 20 (carbon same sulfur) and ("electron emitting") and film and electrode not genes not human not (sulfur same impurities) not hexafluoride not photographic 23:344 EPO; JPO 2003/06/01 23:44 EPO; JPO 2003/09/29 23:44 EPO; JPO 2003/09/29 23:44 EPO; JPO 2003/09/29 2003/09/29 23:44 EPO; JPO 2003/09/29 2003/09/29 23:44 EPO; JPO 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 2003/09/29 | | | | l | |
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